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Please Direct All Correspondence to Customer Number 20995

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**FEE TRANSMITTAL**

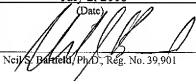
Applicant : Hojo et al.  
App. No : 10/554,380  
Filed : October 26, 2005  
For : POSITIVE PHOTORESIST  
COMPOSITION AND METHOD FOR  
FORMING RESIST PATTERN  
Art Unit : 1795

**CERTIFICATE OF EFS WEB  
TRANSMISSION**

I hereby certify that this correspondence, and any other attachment noted on the automated Acknowledgement Receipt, is being transmitted from within the Pacific Time zone to the Commissioner for Patents via the EFS Web server on:

July 2, 2008

(Date)

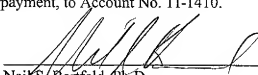
  
Neil S. Bartfeld, Ph.D., Reg. No. 39,901

**Mail Stop Missing Parts  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450**

Dear Sir:

An Information Disclosure Statement was filed in connection with the above-captioned application without the required fee on July 1, 2008, due to difficulties with the electronic filing system. Therefore, the required fee for this IDS is submitted herewith via EFS Web.

The Commissioner is hereby authorized to charge any additional fees which may be required, now or in the future, or credit any overpayment, to Account No. 11-1410.

  
Neil S. Bartfeld, Ph.D.  
Registration No. 39,901  
Agent of Record  
Customer No. 20,995  
(619) 235-8550